

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Applicant:

Lasser et al

Serial No.: 10/735,667

Filed: 16 DEC 2003

For: METHOD OF ARCHIVING DATA

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Group Art Unit:

Attorney Docket No.: 246/233

Examiner:

Commissioner of Patents and Trademarks
Washington, D.C. 20231

INFORMATION DISCLOSURE STATEMENT

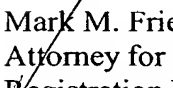
Sir:

Enclosed is PTO Form 1449 which lists citations which may be material to the patentability of the above-identified application.

Also enclosed are copies of the references cited. These are being submitted in compliance with the duty of disclosure defined in 37 C.F.R. 1.56. The Examiner is requested to make these citations of official record in this application.

This Information Disclosure Statement Under 37 C.F.R. 1.56 is not to be construed as a representation that a search has been made, that additional matter which is material to the examination of this application does not exist, or that any one or more of these citations constitutes prior art.

Respectfully submitted,


Mark M. Friedman
Attorney for Applicant
Registration No. 33,883

Date: January 5, 2004

Sheet 1 of 1

Form PTO-1449 (Modified)

Atty. Docket No.
246/233Application No.
10/735,667INFORMATION DISCLOSURE CITATION
IN AN APPLICATION
(USE SEVERAL SHEETS IF NECESSARY)Applicant:
LASSER et alFiling Date:
16 December 2003

Group Art Unit:

U.S. PATENT DOCUMENTS

	EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUB- CLASS	FILING DATE
AA		5,930,167	JUL 99	Lee et al			
AB		6,456,528	SEP 02	Chen			
AC							
AD							
AE							
AF							
AG							
AH							
AI							

FOREIGN PATENT DOCUMENTS

		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB-CLASS	TRANSLATION	
							YES	NO
AJ								

OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)

AK		
AL		
AM		
AN		

EXAMINER

DATE CONSIDERED

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformation and not considered. Include copy of this form with next communication to applicant.